

INTERNATIONAL ORGANIZATION FOR STANDARDIZATION MEXCHAPOCHAR OPI AHUBALIUM TO CTAHCAPTUBALIUM ORGANISATION INTERNATIONALE DE NORMALISATION

Metallic coatings — Measurement of coating thickness — Coulometric method by anodic dissolution

First edition – 1972-06-15 **iTeh STANDARD PREVIEW** (standards.iteh.ai)

<u>ISO 2177:1972</u> https://standards.iteh.ai/catalog/standards/sist/c8a5c869-375e-4f2f-b850-170dfa128d1c/iso-2177-1972

UDC 669.058 : 531.717 : 621.317.39

Ref. No. ISO 2177-1972 (E)

Descriptors : metal coatings, thickness, dimensional measurement, anodic dissolution.

FOREWORD

ISO (the International Organization for Standardization) is a worldwide federation of national standards institutes (ISO Member Bodies). The work of developing International Standards is carried out through ISO Technical Committees. Every Member Body interested in a subject for which a Technical Committee has been set up has the right to be represented on that Committee. International organizations, governmental and non-governmental, in liaison with ISO, also take part in the work.

Draft International Standards adopted by the Technical Committees are circulated to the Member Bodies for approval before their acceptance as International Standards by the ISO Council.

International Standard ISO 2177 was drawn up by Technical Committee IEW ISO/TC 107, Metallic and other non-organic coatings.

It was approved in July 1971 by the Member Bodies of the following countries :

	<u>ISO 2177:1972</u>				
Australia	httpaelstandards.itch.ai/catalogswitt2erla/dst/c8a5c869-375e-4f2f-b850-				
Czechoslovakia	Italy 170df	a126haitand-2177-1972			
Egypt, Arab Rep. of	New Zealand	Turkey			
France	Portugal	United Kingdom			
Germany	Romania	U.S.A.			
Hungary	South Africa, Rep. of	U.S.S.R.			
India	Spain				
Ireland	Sweden				

No Member Body expressed disapproval of the document.

© International Organization for Standardization, 1972 •

Printed in Switzerland

Metallic coatings - Measurement of coating thickness -Coulometric method by anodic dissolution

1 SCOPE AND FIELD OF APPLICATION

This International Standard specifies a procedure for measuring the thickness of metallic coatings by the anodic dissolution method. The electrodeposited coatings and substrates to which it applies are given in Table 1. It may also be used to measure the thickness of coatings applied by other means, if due account is taken of special features such as the presence of an alloy layer.

2 PRINCIPLE

Anodic dissolution of the coating from a well-defined area of the coated surface using a suitable electrolyte.

Indication of the end point of the test by the change in (1) by symbols B1, B2, etc. electrode potential (and hence cell voltage) occurring when the coating is virtually completely removed. **ISO 21**

Calculation of the coating thickness eithers.iteh.ai/catalog/standard

 from the time interval between the start and end of the test if the test is conducted at constant current density; or

- from the quantity of electricity, recorded directly by an integrating meter, consumed in dissolving the coating.

3 TEST APPARATUS

Various types of apparatus may be constructed from readily available components (see Annex A). Suitable complete instruments may also be purchased.

4 ELECTROLYTE

The electrolyte to be used shall be such that :

- there is no reaction with the coating metal in the absence of an impressed flow of current;

- the coating dissolves anodically at 100 % efficiency (or at a nearly constant value close to this);

a marked change in electrode potential occurs as the coating is penetrated and an increasing area of substrate is exposed.

The electrolyte must be chosen in relation to the coating and substrate metals, the current density and electrolyte circulation within the test cell. Typical electrolytes, which have been found satisfactory for use with two types of test apparatus for testing various electrodeposited coatings on specific substrates, are given in Table 2, their applications being listed in Table 1. The electrolytes satisfactory with one type of apparatus are indicated by symbols A1, A2, etc., and those satisfactory with a second type of apparatus

TABLE 1 – Application of typical electrolytes (see Table 2) for electrodeposited coatings

-2177-1972	Substrate (Basis metal)				
Coating	Steel	Copper and copper alloys such as brass	Nickel	Aluminium	Zinc
Cadmium	A1 B1	A1 B1	A1 –	A1 —	
Chromium	A2 B2	A3 B3	A2 B4	A2 B4	
Copper	A4 B5		A4 B6	A4 –	B7
Lead	– B 8	— B8	– B8		
Nickel	A5 B9	A5 B10		A5 B9	
Silver	A6 -	A7 B11	A6 —		
Tin	A3 B12	A3 B12	A3 —	A2 B13	
Zinc	A8 B14	A8 B14	A8 –	A8 —	

NOTE - These electrolytes cannot be adapted to all apparatus and when certain commercial instruments are used, it is therefore desirable to follow the supplier's recommendations.

No.	Electrolyte		Notes
A1	Potassium iodide (KI) : 100 g/l, with traces of iodine		
A2	Sodium sulphate (Na ₂ SO ₄) : 100 g/l		
A3	Hydrochloric acid (HCI) : 73 g/l		Dilute 175 ml of hydrochloric acid
	or	(d = 1.18) to 1 litre	
	Sodium hydroxide (NaOH) : 150 g/l		
A4	Sodium potassium tartrate (NaKC ₄ H ₄ O ₆) : 80 g) in 1 litre	
	Ammonium nitrate (NH ₄ NO ₃) : 100 g		
A5	Ammonium nitrate ($NH_4 NO_3$) : 30 g	in 1 litre	
	Sodium thiocyanate (NaCNS) : 30 g	<u></u>	
A6	Sodium nitrate (NaNO ₃) : 100 g	} in 1 litre	
	Nitric acid (HNO ₃): 5 g	J	
A7	Potassium thiocyanate (KCNS) : 180 g/l		
A8	Sodium chloride (NaCl) : 100 g/l		
B1	Potassium chloride (KCI) : 30 g	in 1 litre	
	Ammonium chloride (NH ₄ Cl) : 30 g	<u> </u>	
B2	Orthophosphoric acid $(H_3 PO_4)$: 186 g	} in 1 litre	Dilute 118 ml of orthophosphoric acid (d = 1, 75) and 10 g of chromic oxide
	Chromic oxide (CrO_3) : 10 g		to 1 litre
B3	Sodium carbonate (Na ₂ CO ₃) : 100 g/l	RD P K	For coatings up to 5 µm
B4	Orthophosphoric acid $(H_3 PO_4) : 98 g/l$ (standar	ds.iteh.a	Dilute 64 ml of orthophosphoric acid $d = 1.75$ to 1 litre
85	Ammonium nitrate (NH ₄ NO ₃) : 800 g	177:1070	
	Ammonium hydroxide (NH, OH): (d = 0.88) 10 ml	2 <u>17/109/10</u> tre ndards/sist/c8a5c8(49-375e-4f2fb850
B6	Potassium sulphate $(K_2 SO_4)$: 100 g 170dfa128d	l cíiso-2177-1972	5) 5750 hEr 0050
	Orthophosphoric acid ($H_3 PO_4$) ($d = 1.75$) : 20 ml		
B7	Fluosilicic acid (H_2SiF_6) : Pure solution	Slightly weaker acid may be used	
	containing not less than 30 % fluosilicic acid		is added to the solution
B8	Sodium acetate (CH ₄ COONa) : 200 g	<u>]</u>	
	Ammonium acetate (CH ₃ COONH ₄) : 200 g	} in 1 litre	
89	Ammonium nitrate (NH ₄ NO ₃) : 800 g)	Make up a fresh solution every 5 days
	Thiourea $[(NH_2)_2 CS] : 3.8 g$	in 1 litre	
B10	Hydrochloric acid (HCI) : 42 g/l		Dilute 100 ml of hydrochloric acid ($d = 1.18$) to 1 litre
B11	Potassium fluoride (KF) : 100 g/l		
B12	Potassium nitrate (KNO ₃) : 100 g		
	Potassium chloride (KCI) : 100 g	f in 1 litre	
B13	Sulphuric acid $(H_2 SO_4)$: 90 g]	Dilute 50 ml of sulphuric acid
	Potassium fluoride (KF):5 g		(d = 1.84) and 5 g of potassium fluoride
B14	Potassium chloride (KCI) : 100 a/l		
	or		
	Sodium chloride (NaCl) : 100 a/l		

TABLE 2 - Typical electrolytes

5 PROCEDURE

Clean the area to be tested with a cloth, wetted with an organic solvent for grease removal if necessary. For certain coatings it may be necessary to employ an additional treatment to ensure that the surface is free from passive films or any conversion coating. Press an electrolytic cell, fitted with a flexible sealing ring and incorporating an annular cathode, on the coating so that a circle of known area is exposed to the test solution. Introduce the test solution into the cell and insert and operate the stirrer if appropriate to the instrument used and the thickness of the deposit. Make the electrical connections, with the specimen anodic.

Continue electrolysis until dissolution of the coating is complete, as indicated by a sudden change in anode potential or cell voltage, and record the quantity of electricity consumed.

Examine the specimen and ensure that removal of the coating is virtually complete over the area enclosed by the seal.

6 CALCULATION OF COATING THICKNESS

Coating thickness is given by the following formula :

$$s = 100k \frac{QE}{A\rho}$$

where

s is the coating thickness, in micrometres;

k is the current efficiency of the dissolution process (equal to 100 in the case of 100 % efficiency);

Q is the quantity of electricity, in coulombs, passed in
dissolving the coating and is given by the formula:
Q = itiTehSTANDA

i being the current in amperes;

t being the test duration in seconds. (standards.iten.al) The presence of an alloy layer at the interface may affect

E is the electrochemical equivalent of the coating the accuracy of the results obtained.

https://standards.iteh.ai/catalog/standards/sist/c8a5c869-375e-4f2f-b850-170dfa128d1c/iso-2177-1972

metal, in grams per coulomb, for the conditions of the test;

A is the area over which the coating is dissolved, in square centimetres;

 ρ is the density of the coating, in grams per cubic centimetre.

The formula may also be expressed as :

$$s = C.Q$$

where C is a constant for a given metal coating, electrolyte and cell. The value of C may be determined experimentally by measuring a coating of known thickness and it is recommended that in practice this should normally be done.

7 ACCURACY OF METHOD

The method is normally accurate within \pm 10%. Higher accuracy may be consistently achieved in particular circumstances. The accuracy may be lower when the coating thickness exceeds 50 μ m or is less than 0.2 μ m.

ANNEX A

DESCRIPTION OF TYPES OF APPARATUS

A.1 GENERAL

With one type of circuit the current through the test cell has to be controlled to a constant value, a clock then being used to measure the time interval between the start and end point of the test. Alternatively an integrating meter may be used to measure the quantity of electricity passed, in which case accurate control of the current and separate measurement of the time interval are unnecessary.

The end point can be determined by observing the sudden change in cell voltage on a suitable voltmeter, or a relay switch can be used to automatically terminate the test. In the latter case, the relay is set to operate at a pre-determined value of either the cell voltage or the rate of increase of cell voltage.

Suitable currents for testing the coating thickness on a defined area of approximately 0.2 cm² within a reasonable time are approximately 20 mA for relatively thin coatings, all like chromium, and 80 mA for relatively thick coatings, like

nickel – i.e. the current densities employed for dissolution should conveniently be approximately 1 to 4 kA/m^2 .

A.2 ELECTROLYTIC CELL

The electrolytic cell consists of a cylindrical container applied to the article under test through an intermediary non-conductive and elastic seal (for example rubber or plastics material). The cell itself, if it is made of metal (for example stainless steel), will be the cathode, in which case the seal will also serve as insulation between cathode and anode.

If the cell is of insulating material, a separate cathode is used and is immersed in the electrolyte before starting the test.

The area of surface enclosed by the seal shall be well defined and small enough (approximately 0.2 cm^2) to permit its application to a surface which is curved. Smaller cells may be required for measuring the thickness of coatings on intricate shapes but these pose problems connected with the definition and measurement of the area of the seal. With any cell the accuracy of the method is largely controlled by the accuracy of measurement of the area on which the test is applied.

Normally it is necessary to provide means of agitating the electrolyte in the cell to minimize changes in cell voltage occurring before the end point of the test has been reached.

ISO 2177:1972

https://standards.iteh.ai/catalog/standards/sist/c8a5c869-375e-4f2f-b850-170dfa128d1c/iso-2177-1972

iTeh STANDARD PREVIEW (standards.iteh.ai)

ISO 2177:1972 https://standards.iteh.ai/catalog/standards/sist/c8a5c869-375e-4f2f-b850-170dfa128d1c/iso-2177-1972

iTeh STANDARD PREVIEW (standards.iteh.ai)

<u>ISO 2177:1972</u> https://standards.iteh.ai/catalog/standards/sist/c8a5c869-375e-4f2f-b850-170dfa128d1c/iso-2177-1972

.